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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/809,700	03/26/2004	Kyle W. Hukari	251193US40DIV	8151
22850 7	22850 7590 06/05/2006		EXAMINER	
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C.			TURNER, ARCHENE A	
1940 DUKE S ALEXANDRI	TREET A, VA 22314		ART UNIT	PAPER NUMBER
	,		1775	
		DATE MAILED: 06/05/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

		<u> </u>				
		Application No.	Applicant(s)			
		10/809,700	HUKARI ET AL.			
	Office Action Summary	Examiner	Art Unit			
		Archene Turner	1775			
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the c	correspondence address			
WHIC - Exte after - if NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DATE of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. O period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tire will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status						
1)⊠	Responsive to communication(s) filed on 3/04.					
2a)□	This action is FINAL . 2b)⊠ This	action is non-final.				
3)[Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
	closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 49	53 O.G. 213.			
Dispositi	ion of Claims					
4)⊠ 5)□	Claim(s) <u>41-79</u> is/are pending in the application 4a) Of the above claim(s) is/are withdraw Claim(s) is/are allowed. Claim(s) <u>41-79</u> is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or	vn from consideration.				
Applicati	ion Papers					
_	The specification is objected to by the Examine	r				
	10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.					
•	Applicant may not request that any objection to the					
	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).					
11)☐ The oath or declaration js objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority ι	ınder 35 U.S.C. § 119					
12) <u>□</u> a)[Acknowledgment is made of a claim for foreign All b) Some * c None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau See the attached detailed Office action for a list	s have been received. s have been received in Applicati ity documents have been receive I (PCT Rule 17.2(a)).	on No ed in this National Stage			
Attachmen	t(s)					
1) Notic	e of References Cited (PTO-892)	4) Interview Summary				
2) Notic	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	Paper No(s)/Mail Da				
	r No(s)/Mail Date 3/04 &5/04.	6) Other:	atom Application (F 10-102)			

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1. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

- 2. Claims 41-67 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the enablement requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention. The claims provide for a metal oxynitride layer, which is only provided for in the original disclosure after the removal of the carbon layer (see page 10, lines 20-22).
- 3. Claims 50,63 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the enablement requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention. The claims provide for a metal oxynitride layer, which is only provided for in the original disclosure after the removal of the carbon layer.
- 4. Claims 51,64 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the enablement requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the

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invention. The claims provide for a doped carbon layer, but the disclosure calls for doping when 1-10% nitrogen is included in the inert gas which calls for a specific amount of dopant in the layer.

- 5. Claims 41,43-55,58-68,71-78 are rejected under 35 U.S.C. 112, first paragraph, as based on a disclosure which is not enabling. A transparent substrate is critical or essential to the practice of the invention, but not included in the claim(s) is not enabled by the disclosure. See *In re Mayhew*, 527 F.2d 1229, 188 USPQ 356 (CCPA 1976).
- 6. Claims 41-53,55-66,68-78 are rejected under 35 U.S.C. 112, first paragraph, as based on a disclosure which is not enabling. The carbon layer having a thickness from 1 to 10 nm is critical or essential to the practice of the invention, but not included in the claim(s) is not enabled by the disclosure. See *In re Mayhew*, 527 F.2d 1229, 188 USPQ 356 (CCPA 1976).
- 7. Claims 41-47, 49-75, 78-79 are rejected under 35 U.S.C. 112, first paragraph, as based on a disclosure which is not enabling. The scratch propagation layer having a thickness of 2 to 8 nm is critical or essential to the practice of the invention, but not included in the claim(s) is not enabled by the disclosure. See *In re Mayhew*, 527 F.2d 1229, 188 USPQ 356 (CCPA 1976).

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8. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 9. Claims 41-67 are rejected under 35 U.S.C. 102(e) as being anticipated by Veerasamy et al (6,447,891).

Veerasamy et al discloses the claimed carbon coating on an optical coating having the claimed components and thickness (column 5, line 50-56). The amorphous structure in claims 41-67 is considered inherent to how the silicon nitride layer is made.

10. Claims 68-79 are rejected under 35 U.S.C. 102(b) as being anticipated by Stachowiak (6,586,102).

Stachowiak discloses the claimed optical coating within the claimed thickness on glass. The amorphous structure in claim 74 is considered inherent to how the silicon nitride layer is made.

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11. Claims 68-79 are rejected under 35 U.S.C. 102(e) as being anticipated by Stachowiak (6.830,817 or 6,589,658).

Stachowiak discloses the claimed optical coating within the claimed thickness on glass. The amorphous structure in claim 74 is considered inherent to how the silicon nitride layer is made.

- 12. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 13. Claims 41-67 are rejected under 35 U.S.C. 103(a) as being unpatentable over Veerasamy (6,713,179 or 6,303,225) and Stachowiak (6,586, 102 or 6,589,658 or 6,830,817).

Veerasamy discloses the known used of carbon coatings within the claimed thickness used on optical coatings.

Stachowiak discloses the known optical coatings on glass.

Thus it would have been obvious to one of ordinary skill in the art to provide Veerasamy with the optical coating of Stachowiak or provide the carbon coating of Veerasamy onto the optical coating of Stachowiak, as this combination would have been known to one of ordinary skill in the art to improve performance of the optical coatings.

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Regarding the amorphous structure of the silicon nitride layer in claims 41-54, the amorphous structure is considered inherent to how the silicon nitride layer is made.

14. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Archene Turner whose new telephone number is (571) 272-1545. The examiner can normally be reached on Monday, Wednesday through Friday from 10:30 am. to 6:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Jennifer McNeil can be reached on (571) 272-1540. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306. Please remember to include on the fax, the art unit 1775, serial number and Examiner's name.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

ARCHENETURNER PRIMARY EXAMINER